IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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GAU2815

In re the Application of: Kiyo Ai WEI

Serial No.: 09/428,052

Filed: October 27, 1999

Group Art Unit: 2815

Examiner: J. Diaz

For: METHOD OF FABRICATING A SEMICONDUCTOR DEVICE CONTAINING

NITROGEN IN A GATE OXIDE FILM (AS AMENDED)

PETITION FOR EXTENSION OF TIME

Commissioner for Patents Washington, D.C. 20231

Date: May 24, 2001

Sir:

Applicant petitions the Commissioner for Patents to extend the time for response to the Office Action dated January 26, 2001, for one month from April 26, 2001, to May 26, 2001.

Attached please find a check in the amount of \$110.00 to cover the cost of the extension. In the event that any additional fees are due in connection with this paper, please charge our Deposit Account No. 01-2340. This paper is filed in triplicate.

Respectfully submitted,

ARMSTRONG, WESTERMAN/HATTORI, McLELAND & NAUGHTON, LLP

Stephen G. Adrian Reg. No. 32,878

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